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In mathematics, physics, and art, moiré patterns are large-scale interference patterns... For the moiré interference pattern to appear, the two patterns must not be completely identical, but rather displaced, rotated, or have slightly different pitch.

Twistronics (from twist and electronics) is the study of how the angle (the twist) between layers of two-dimensional materials can change their electrical properties.

twistronics + moiré → over 20,000 papers

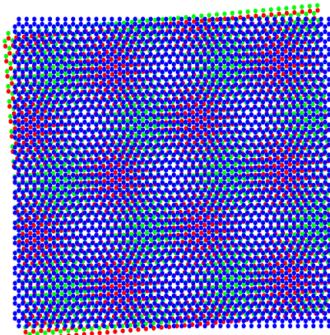
**Morning: Moiré
superlattices in graphene**

**Afternoon: Twistronics of
transition metal dichalcogenides**

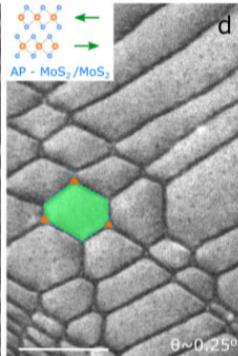
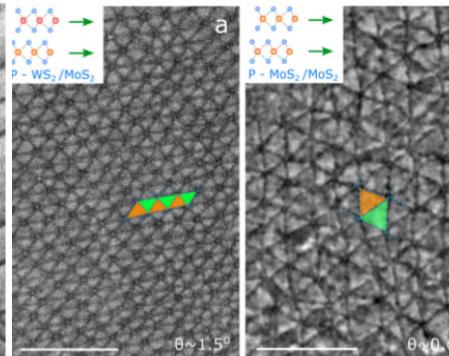
2D materials family

strongly covalent-bonded atomically thin planes extracted from layered crystals
with much weaker van der Waals adhesion between the layers

chemically stable
mechanically robust
bendable
&
stretchable



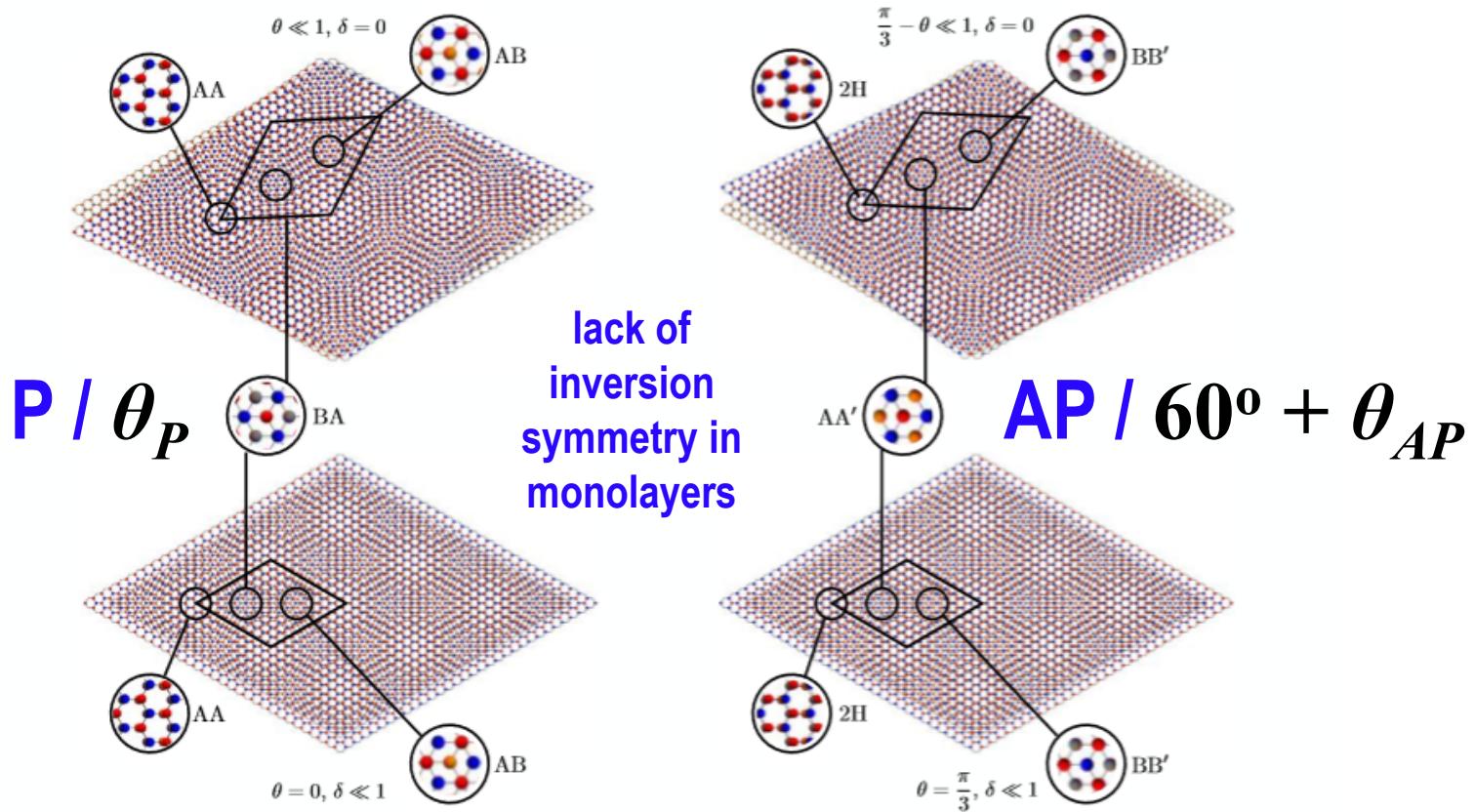
collectively, the already
which can be further ex

Graphene	hBN 'white graphene'	BCN	Fluorographene	Graphene oxide
	Transition metal dichalcogenides (TMD) MoS_2 , WS_2 , MoSe_2 , WSe_2	Semiconducting dichalcogenides: MoTe_2 , WTe_2 , ZrS_2 , ZrSe_2 and so on	Metallic dichalcogenides: NbSe_2 , NbS_2 , TaS_2 , TiS_2 , NiSe_2 and so on superconductors at low temperatures	
Micas, BSCCO	MoO_3 , WO_3		Layered semiconductors: GaSe , GaTe , InSe , Bi_2Se_3 and so on	
		Perovskite-type: LaNb_2O_7 , $(\text{Ca}, \text{Sr})_2\text{Nb}_3\text{O}_{10}$	Magnetic CrCl_3 , Crl_3 , CrBr_3 RuCl_3 ,	
				

Twistronics of transition metal dichalcogenides

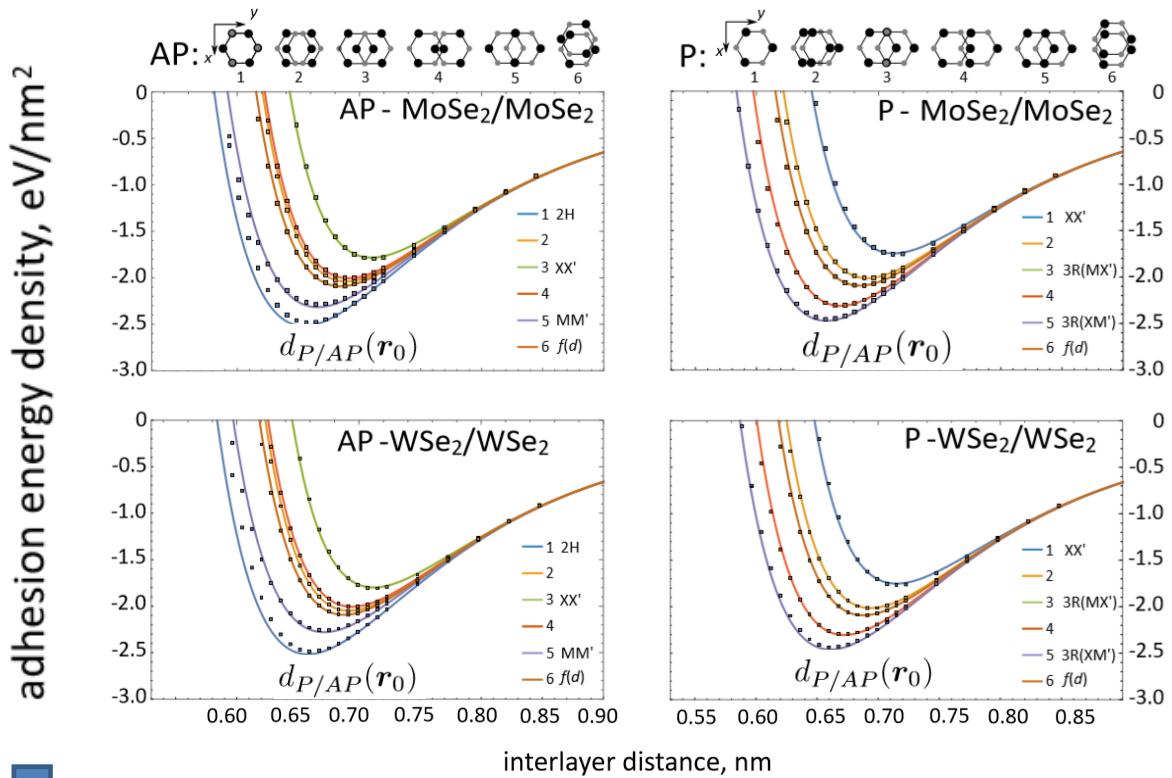
- Structure of twisted bilayers – reconstruction into domains and domain wall networks
- Bilayer with inversion symmetry (AP) and without it (P)
- Ferroelectric interfaces and layer-asymmetric band edges in TMDs
- Switching FE polarisation by sliding and ‘string theory’ for domain wall networks
- Band-edge profiles, arrays of QDs, and ‘narrow moiré minibands’
- Ferroelectric few-layer graphene

Moiré superstructures in TMD bilayers



are sensitive to P/AP orientation of unit cells in each layer,
due to their inversion asymmetry

$\text{MX}_2/\text{M}'\text{X}'_2$ adhesion energy: *ab initio* DFT input



DFT-parametrised for all MX_2
homo- & heterobilayers

$\text{M} = \text{Mo, W}$
 $\text{X} = \text{S, Se}$

sets optimal interlayer distance for each
offset r_0 between top/bottom layer lattices



$$W_{P/AP}(r_0, d) = - \sum_{n=1}^3 \frac{C_{4n}}{d^{4n}} + \sum_{n=1}^3 \left[A_1 e^{-\sqrt{G^2 + \rho^{-2}} d} \cos(G_n r_0) + A_2 e^{-Gd} \sin(G_n r_0 + \varphi_{P/AP}) \right]$$

Mesoscale lattice relaxation (modelling)

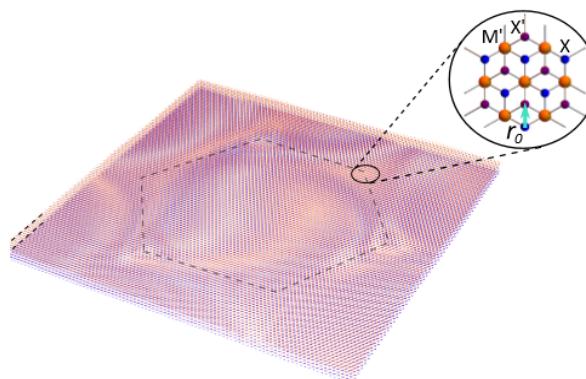
minimise elastic + adhesion energy

$$\sum_{l=t,b} \left[(\lambda_l/2) \left(u_{ii}^{(l)} \right)^2 + \mu_l \left(u_{ij}^{(l)} \right)^2 \right] + W_{P/AP}(\mathbf{r}_0, d)$$
$$d_{P/AP}(\mathbf{r}_0)$$
$$\mathbf{r}_0(\mathbf{r}) = \theta \hat{z} \times \mathbf{r} + \delta \mathbf{r} + \mathbf{u}^{(t)} - \mathbf{u}^{(b)}$$

for all MX_2 bilayers
 $\text{M} = \text{Mo, W}; \text{ X} = \text{S, Se}$

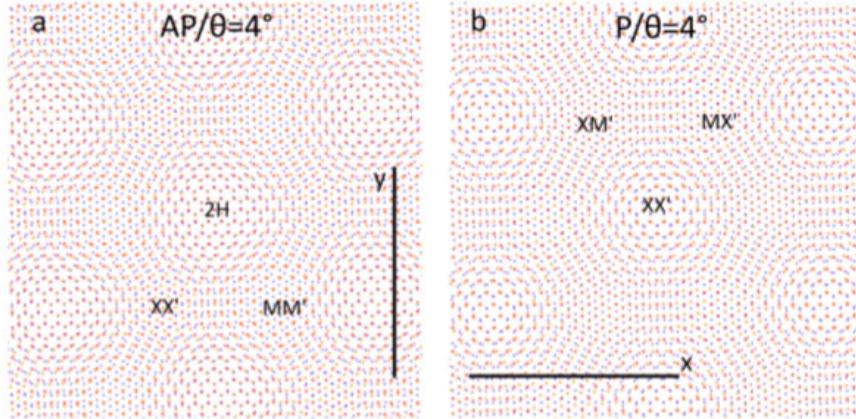
δ – lattice mismatch

θ – misalignment angle



Short-period and long-period moiré structures

large angle or different chalcogens: almost rigid short-period superlattice



$$\ell \approx a / \sqrt{\theta_{P,AP}^2 + \delta^2}$$

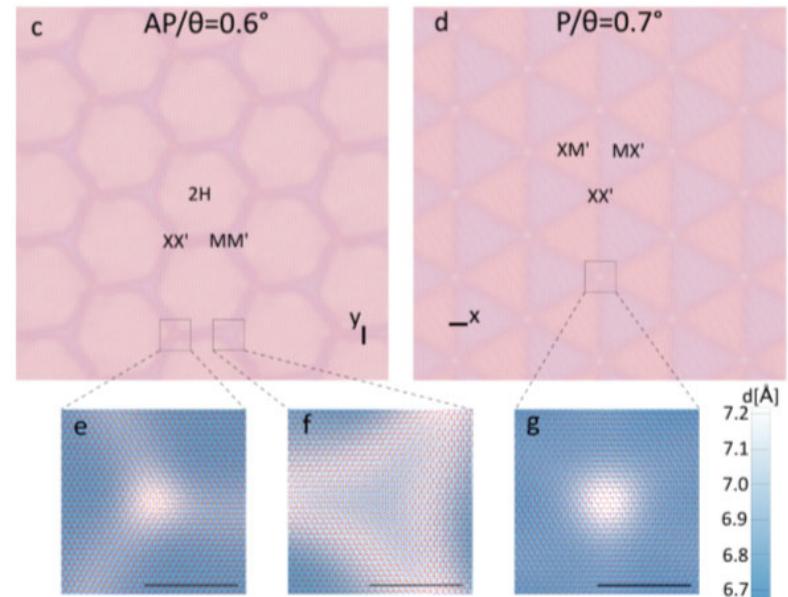
twisted homobilayers: strain is almost pure shear deformations in both layers

same-chalcogen heterobilayers with $\delta < 1\%$: shear and hydrostatic strain (biaxial) components in each layer

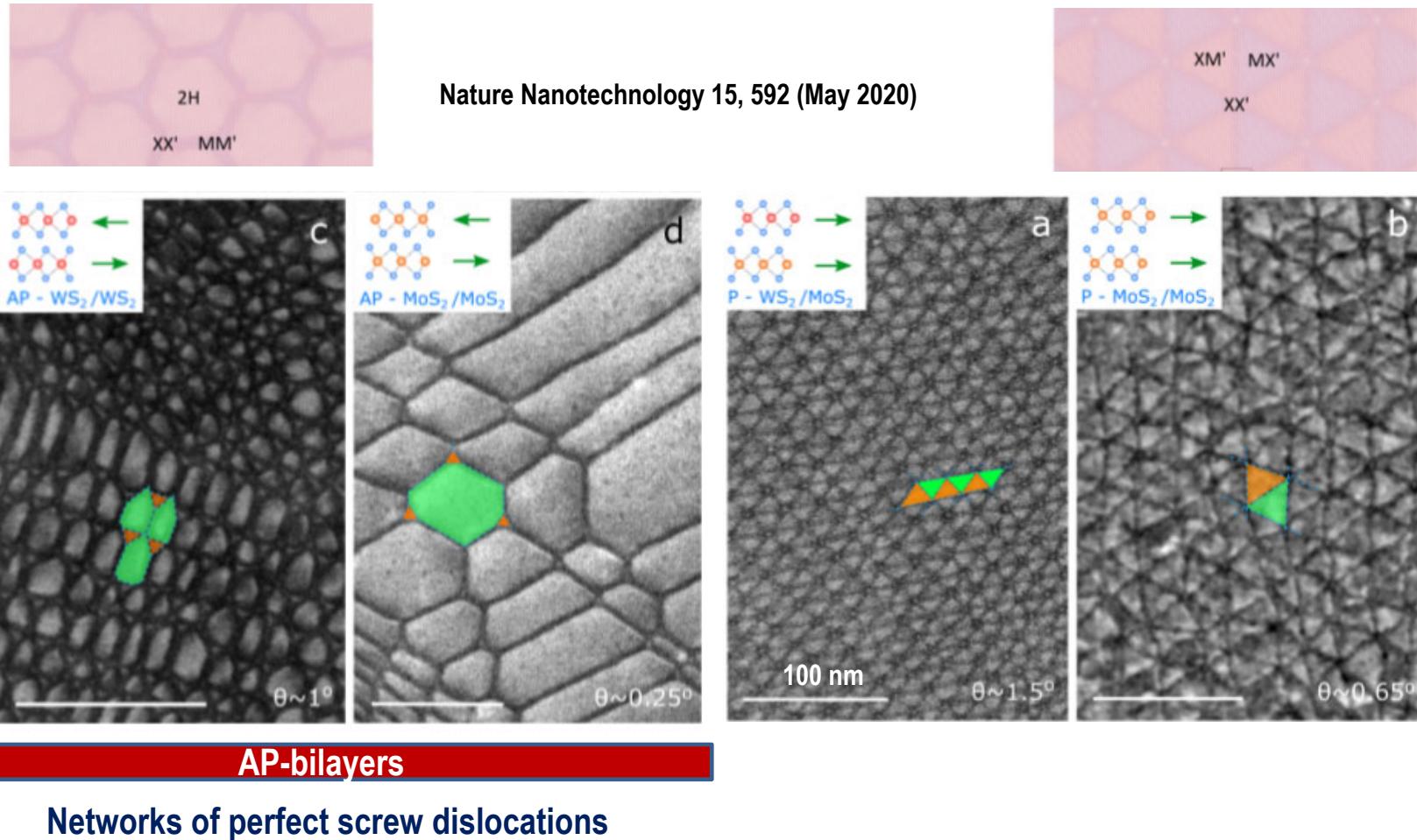
$$\theta_{AP}^* \approx 1.0^\circ$$

$$\theta_P^* \approx 2.5^\circ$$

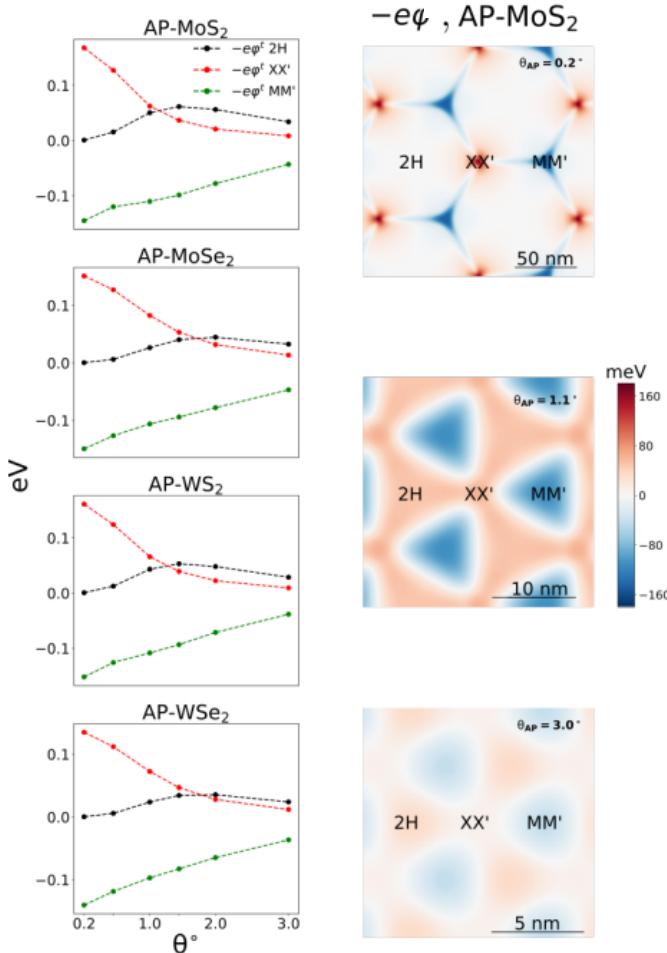
small angle same-chalcogen bilayers: domains separated by dislocations



Domains and domain wall networks: STEM



Piezoelectric domain wall (DW) networks in AP-MX₂ homobilayers

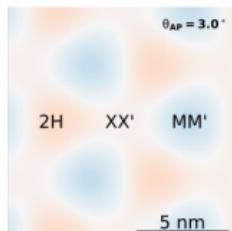
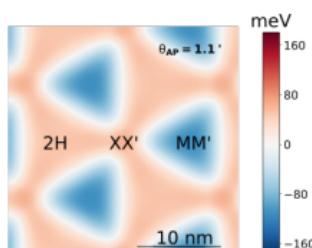


same sign of piezocharges
in top & bottom layers

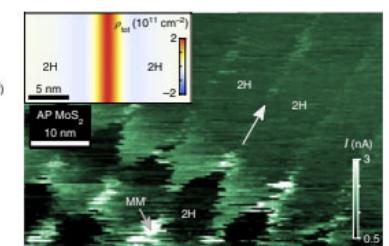
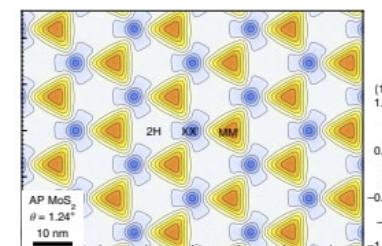
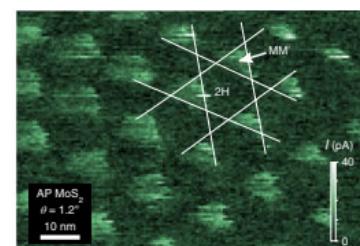
$$\rho = e_{11} [2\partial_x u_{xy} + \partial_y(u_{xx} - u_{yy})]$$

$$e_{11}^t = -e_{11}^b$$

$$u_{ij}^t = -u_{ij}^b$$



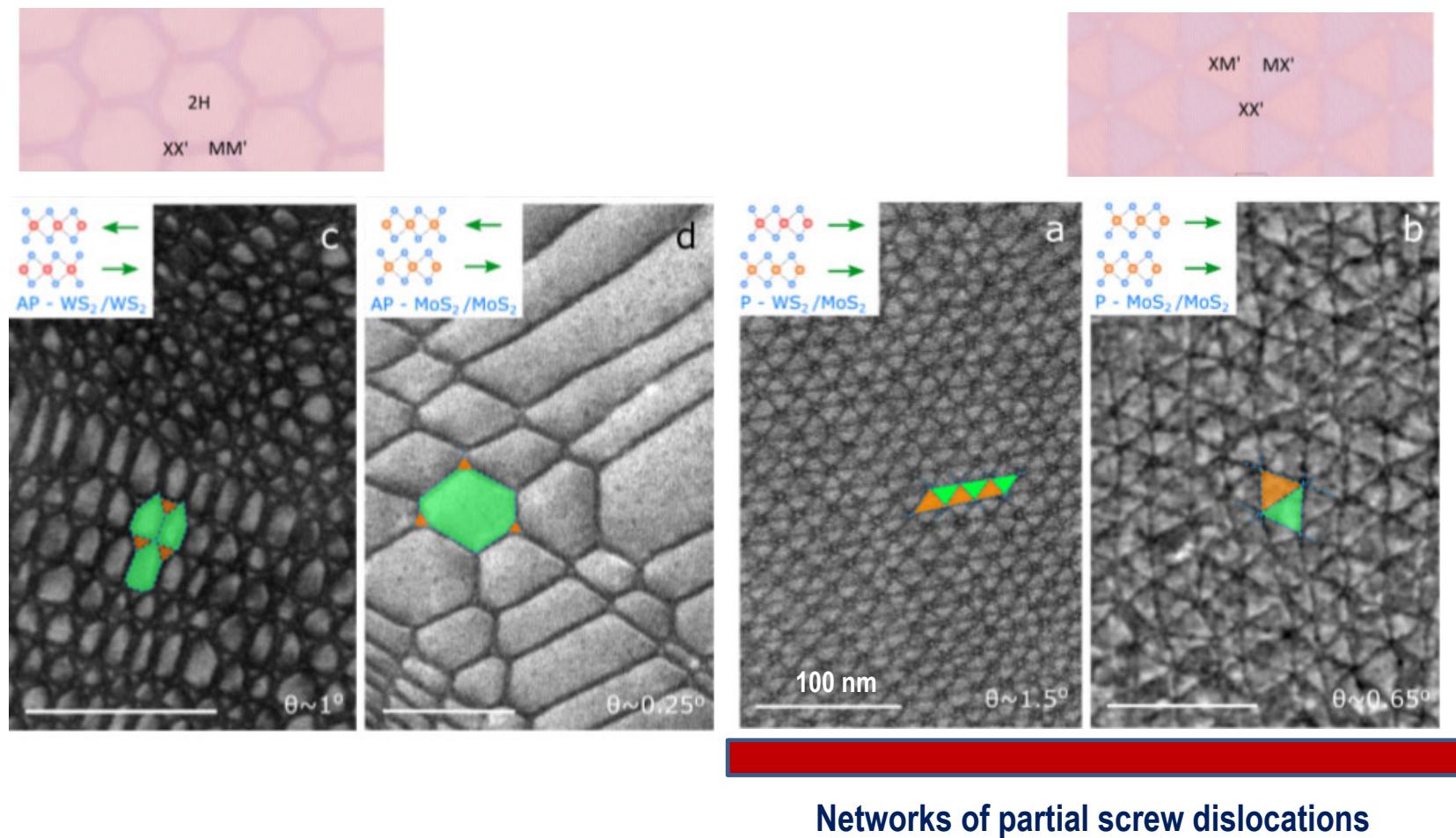
Conducting atomic force microscopy (cAFM) and scanning Kelvin probe microscopy (SKPM) revealed piezoelectric charge modulation near DW networks



Twistronics of transition metal dichalcogenides

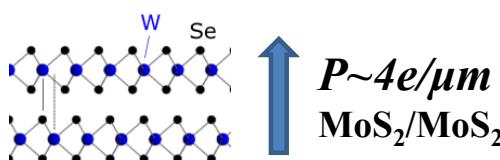
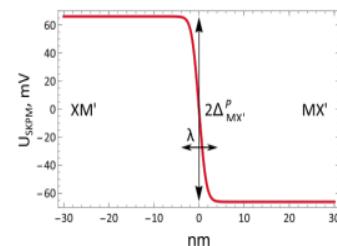
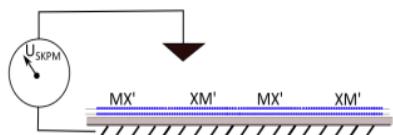
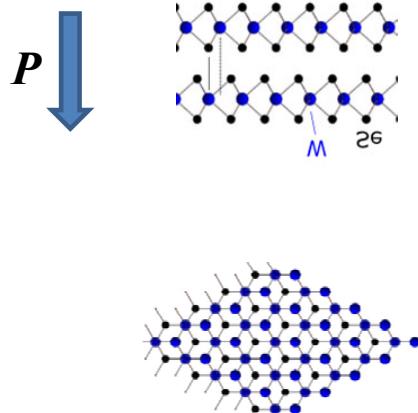
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Domains and domain wall networks: P-bilayers



Weak ferroelectricity in P-homobilayers of TMDs ('R-stacking')

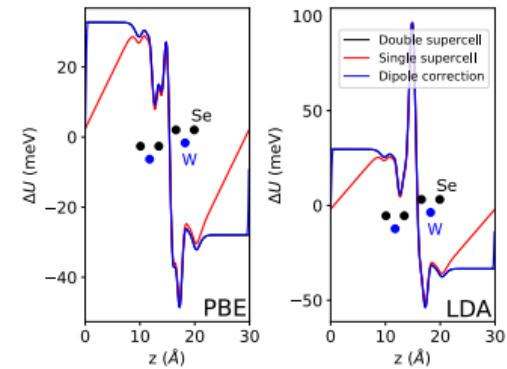
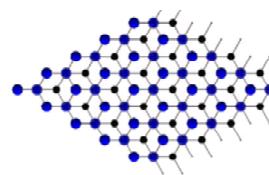
spontaneous vertical polarisation due to the interlayer hybridisation of chalcogen orbitals in homobilayers with a broken-symmetry interface (MX and XM) reversible by sliding



$$P \sim 4e/\mu\text{m}$$

$$\text{MoS}_2/\text{MoS}_2$$

	$\Delta^P(\text{MX}')$ (meV)
MoS ₂	69
MoSe ₂	67
WS ₂	63
WSe ₂	66(61)

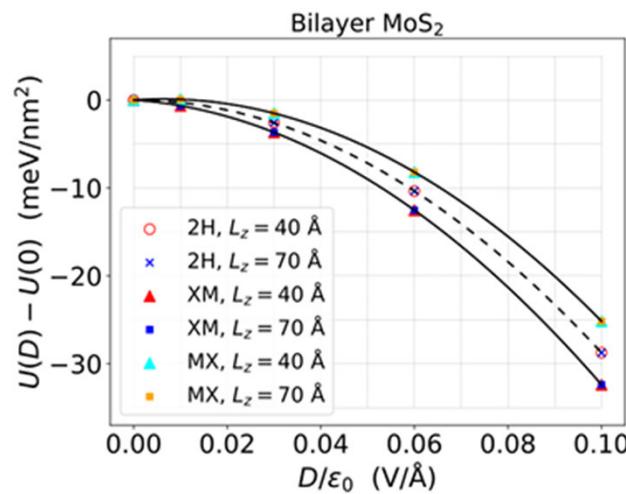


twin structures which can be converted into each other by sliding

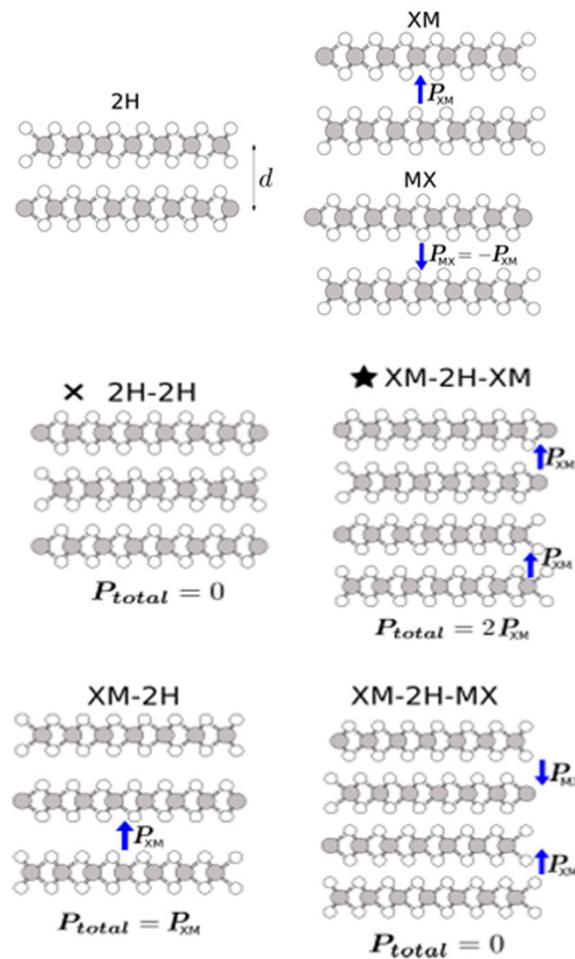
Scientific Reports 11, 13422 (2021)

Additive weak ferroelectricity in combinatorial P-homobilayers of TMDs and hBN

$$U - U_0 = -\frac{PD}{\epsilon_0} - \frac{1}{2} \frac{\alpha_{zz}^{2L} D^2}{\epsilon_0 \mathcal{A}}$$

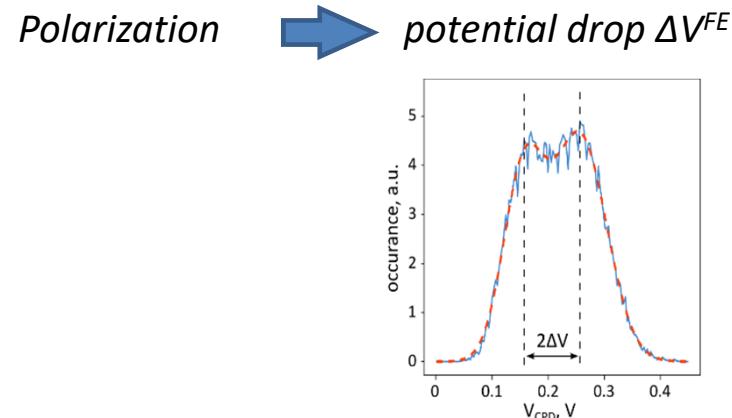
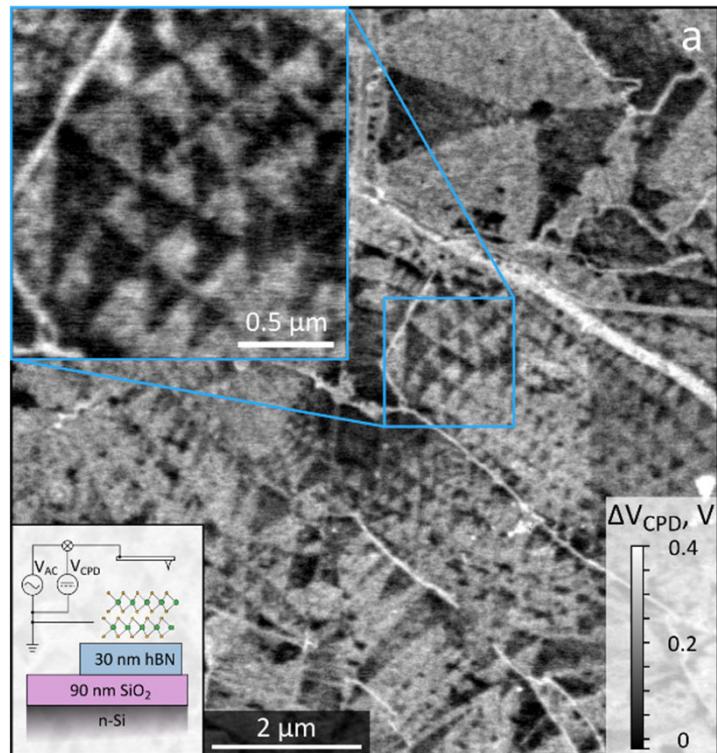


Phys Rev B 106, 125408 (2022)



	hBN	FP interfaces	P ($10^{-4} e/\text{\AA}$)
1L			0
2L	BN ^{AP}		0
	BN ^P	P_{BN}	5.5
	NB ^P	P_{NB}	-5.4
3L	BN ^{AP} -BN ^{AP}		0
	BN ^P -NB ^P	$P_{BN} + P_{NB}$	0
	BN ^P -BN ^P	$2P_{BN}$	11.7
4L	BN ^{AP} -BN ^{AP} -BN ^{AP}		0
	BN ^P -NB ^P -BN ^P	$2P_{BN} + P_{NB}$	6.3
	BN ^P -BN ^P -BN ^P	$3P_{BN}$	17.9

Kelvin microscopy of ferroelectric domains in marginally twisted MoS₂



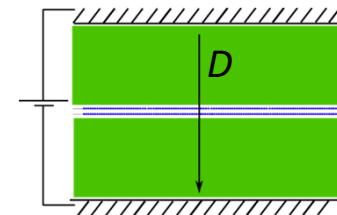
SKPM of MoS₂ bilayers gives $\Delta=60$ meV

	ΔV^{FE} [mV]
MoS ₂	69
MoSe ₂	67
WS ₂	63
WSe ₂	66(61)

Nature Nano 17, 390 (2022)

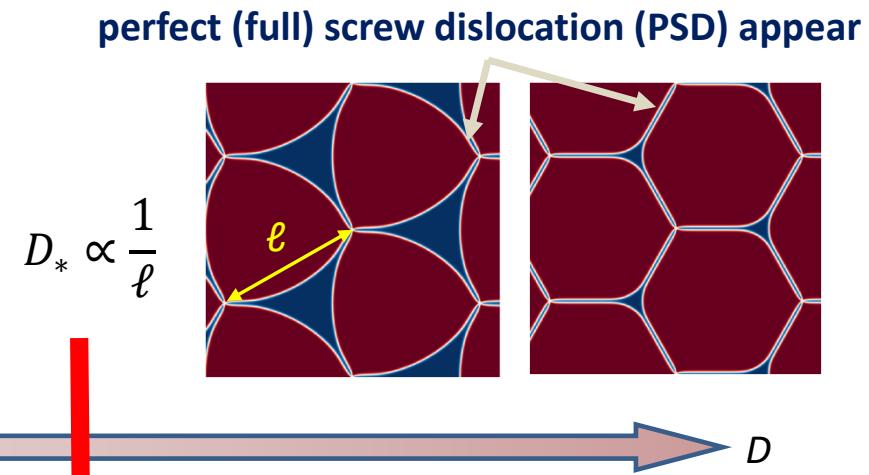
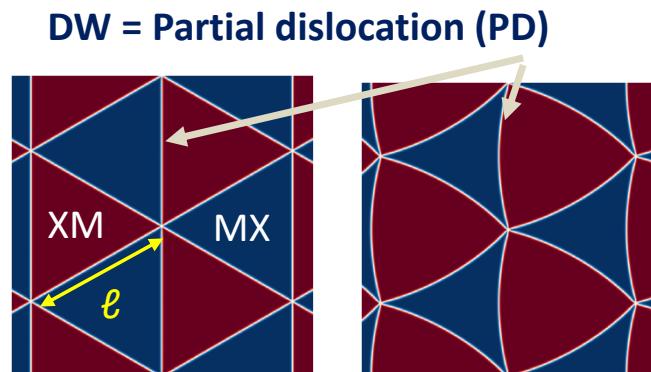
Scientific Reports 11, 13422 (2021)

Electrically tuneable domain structure

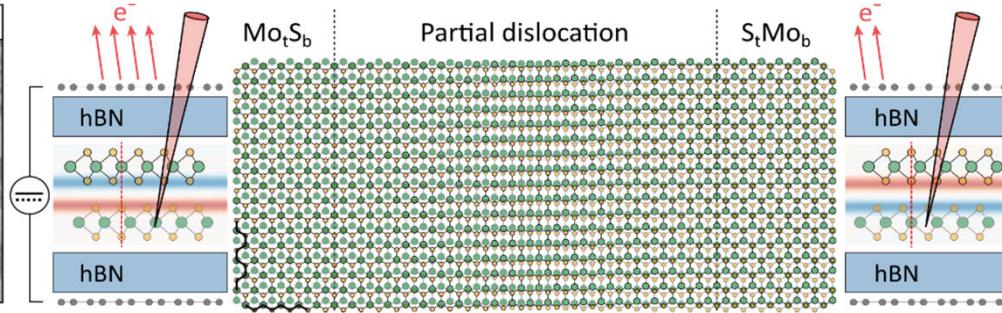
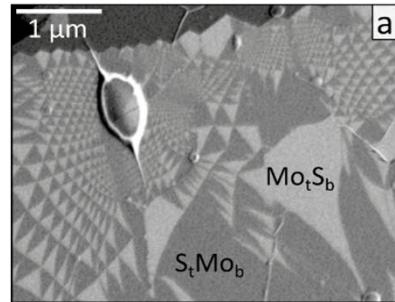


makes XM and MX
energetically
inequivalent
in electric field

$$\mathcal{E} = \sum_{a=t,b} [\lambda(u_{ii}^a)^2 + \mu u_{ij}^a u_{ji}^a] + W(\vec{r}_0, d) - DP(\vec{r}_0, d) \rightarrow \vec{u}^{t/b}$$

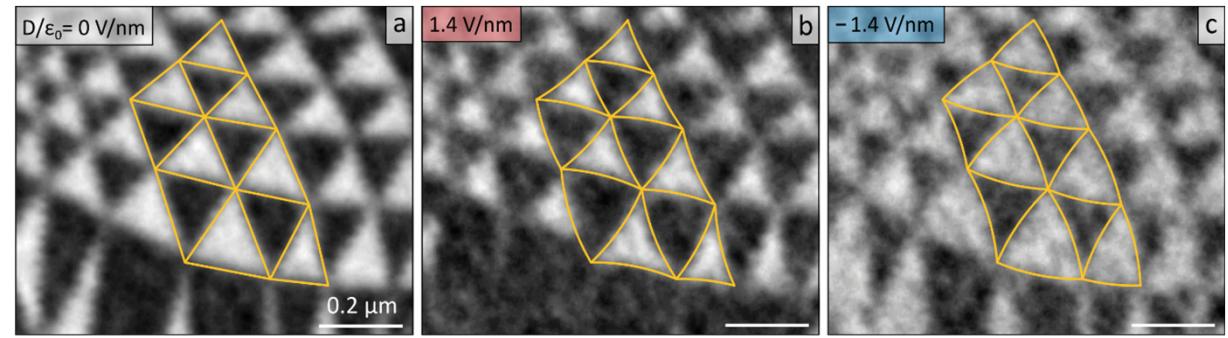


Electrically tuneable domains in MoS₂/MoS₂

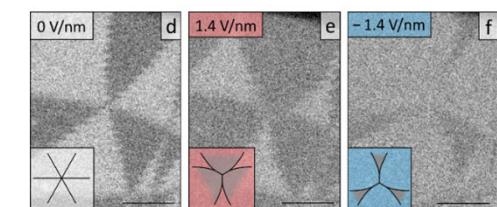
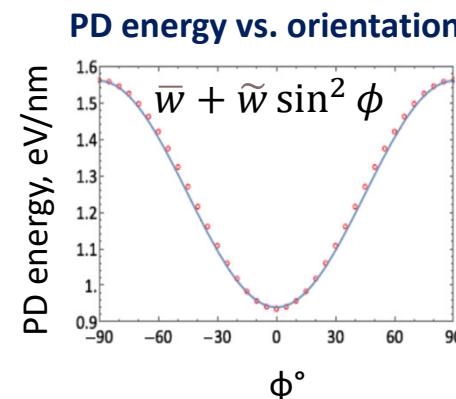
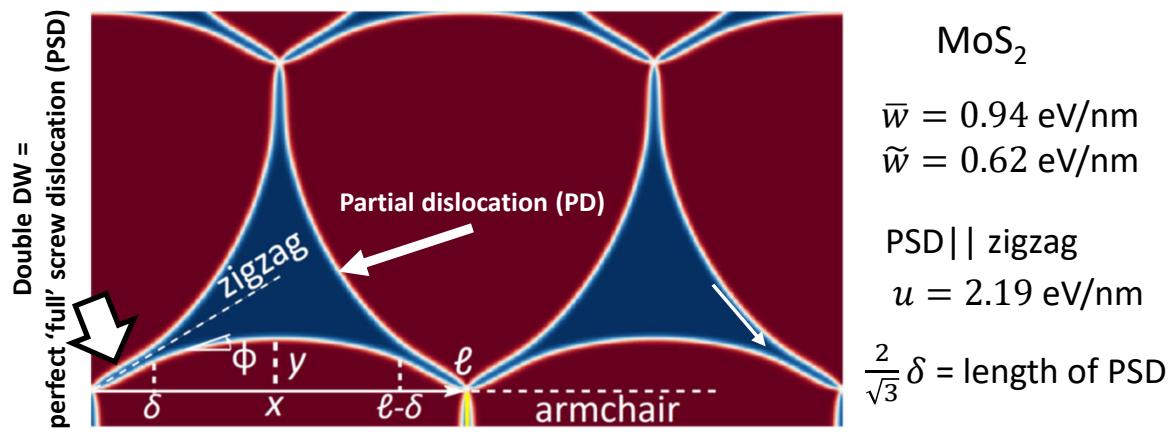


back-scattered
electron channelling
contrast imaging

polarisation is reversed by
interlayer sliding near
domain boundaries,
detected by SEM imaging



'string theory' of tuneable domain wall networks



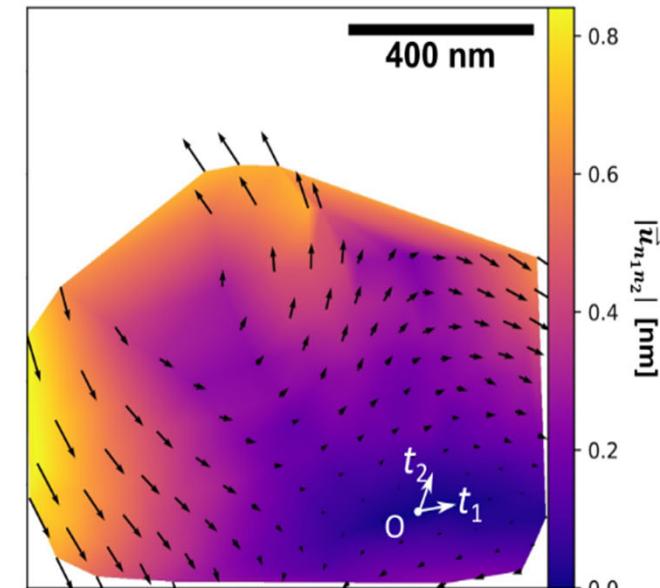
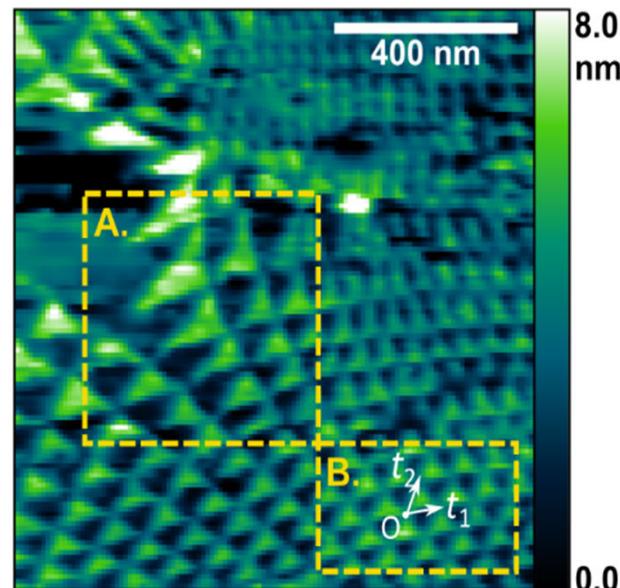
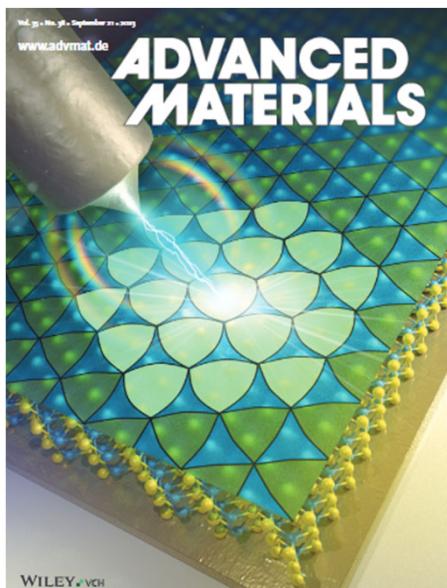
$$\mathcal{E}_\ell [y(x), \delta] = 3 \int_{\delta}^{\ell-\delta} \left[\underbrace{\left(\bar{w} + \tilde{w} \frac{y'^2}{1+y'^2} \right) \sqrt{1+y'^2}}_{\text{PD energy}} - 2 \frac{\Delta V^{FE} D}{\chi} y \right] dx + 3 \left[\underbrace{u \frac{2\delta}{\sqrt{3}}}_{\text{PSD energy}} - 2 \underbrace{\frac{\Delta V^{FE} D}{\chi \sqrt{3}} \delta^2}_{\text{expansion of favorable domains}} \right]$$

universal solution

$$D_* = \frac{\chi \left(\frac{\bar{w}}{2} + \frac{7\tilde{w}}{8} \right)}{\Delta V^{FE} \ell}$$

threshold displacement field

Moiré pattern as a magnifying glass for small intra-layer deformations (traced by following XX stacking nodes)



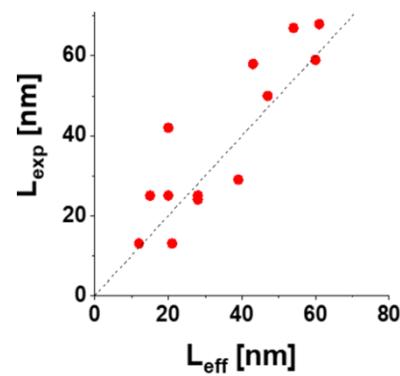
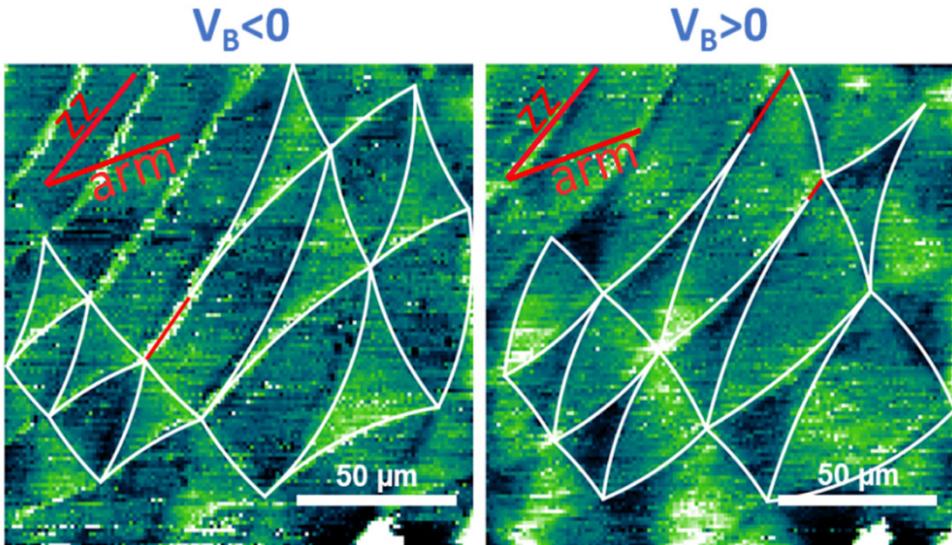
STM mapping of
a twisted
WS₂ P-bilayer

$$\vec{u}(\vec{R}_{n_1, n_2}) = \theta \hat{z} \times \vec{R}_{n_1, n_2} - n_1 \vec{a}_1 - n_2 \vec{a}_2$$

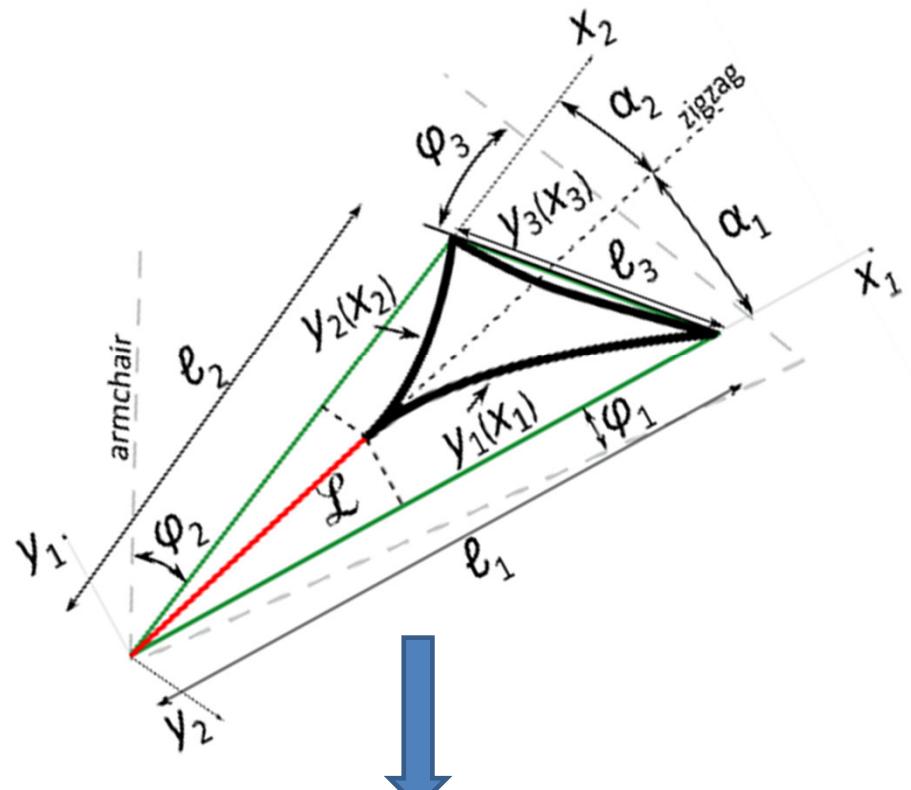
Advanced Materials 35, 2370273 (2023)

Faraday Discussions 173, 137 (2014); Ann der Phys 527, 359 (2015)

'String theory' for tuneable domain wall networks: comparison with STM data taken on WS₂ bilayers

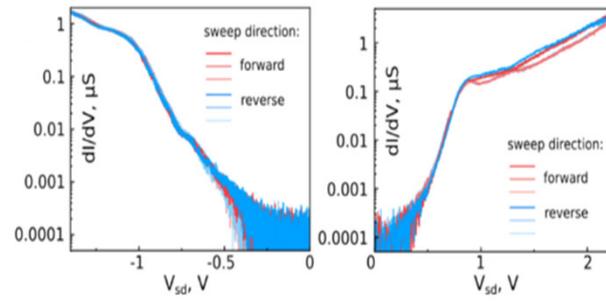
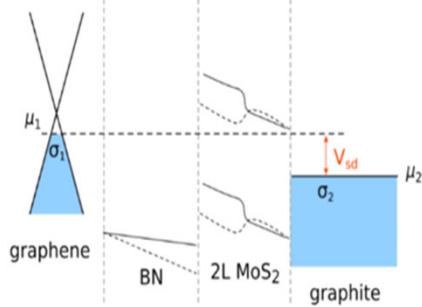
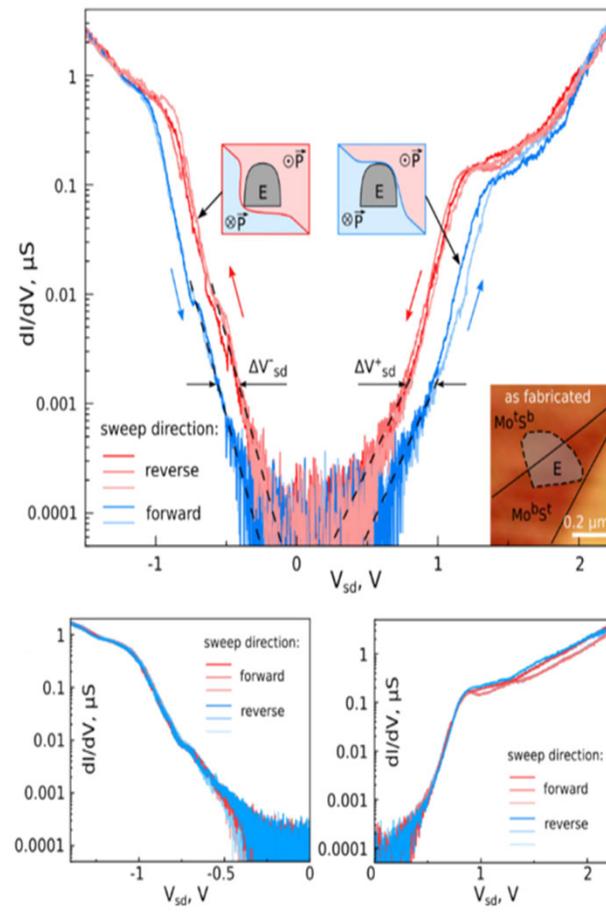
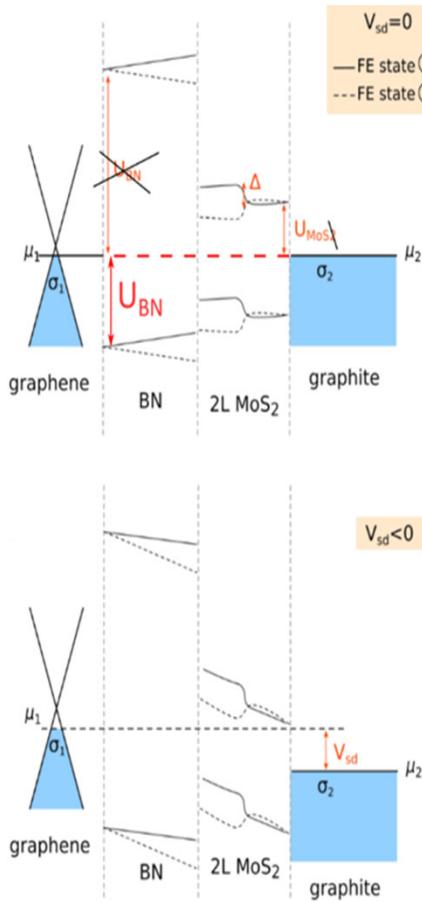


Advanced Materials 35, 2370273 (2023)



'string theory' generalised for
anisotropically shaped domains.

Polarisation and hysteresis in the FE tunnelling transistor



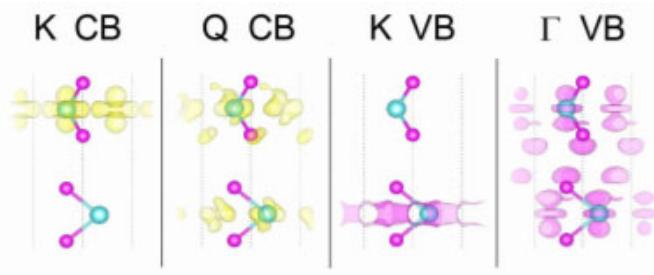
$$\ln \left. \frac{dI}{dV_{sd}} \right|_{V_{sd} > 0} \propto |eV_{sd}| \pm \frac{\delta_>}{2}, \quad \delta_> \approx \frac{2\sigma(1+\theta)}{2+\sigma+\theta} \Delta$$

$$\ln \left. \frac{dI}{dV_{sd}} \right|_{V_{sd} < 0} \propto |eV_{sd}| \pm \frac{\delta_<}{2}, \quad \delta_< \approx \frac{2\sigma(1+\theta)}{2\theta\sigma+\sigma+\theta} \Delta$$

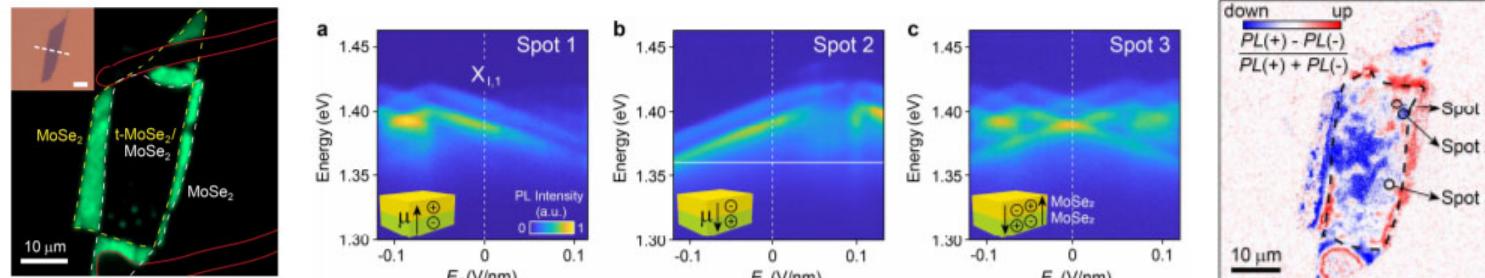
$$\sigma = \frac{d_{BN}}{d_{MoS}} \frac{\epsilon_{MoS}}{\epsilon_{BN}}, \quad \theta = \frac{d_{MoS}}{d_{BN}} \sqrt{\frac{m_{MoS} U_{BN}^3}{m_{BN} U_{MoS}^3}}$$

NGI team, unpublished (2023)

Layer-asymmetric band edge states in optics opposite linear Stark shifts for excitons in MX' and XM' stacking domains



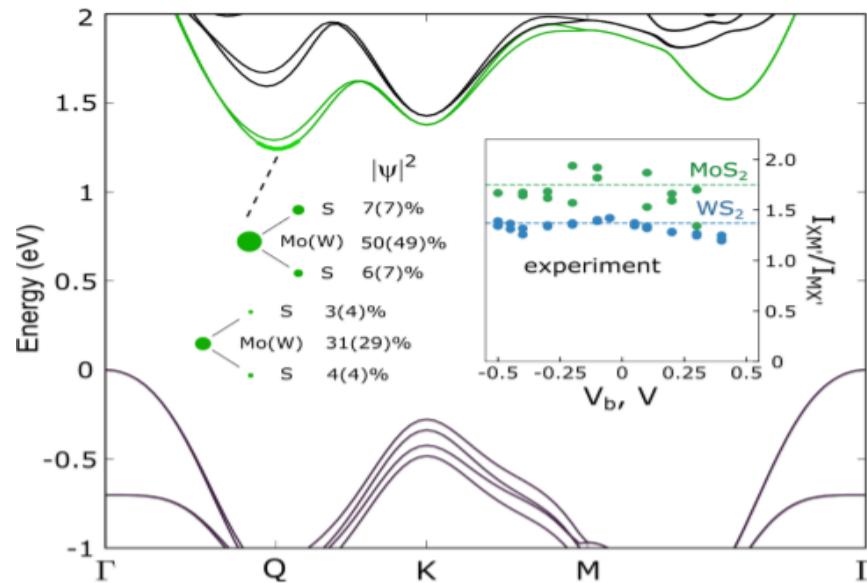
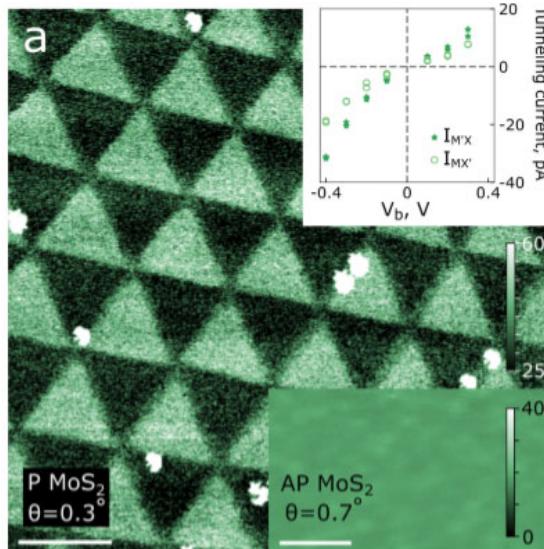
$ \psi ^2$ (%)	K CB	Q CB	K VB	Γ VB
Se	3.8	6.5	0.0	1.0
Top Mo	92.2	42.6	0.7	31.9
Se	3.8	10	0.2	14.3
Bottom Mo	0.0	6.8	7.5	14.9
Se	0.1	29.7	84.0	36.6
d_z (e·nm)	0.322	0.058	-0.317	-0.017



Possible optical
read-out of
gate-controlled
P-bilayer
transistor

Layer-asymmetric band edge states in P-MoS₂/MoS₂ and P-WS₂/WS₂: tunnelling characteristics

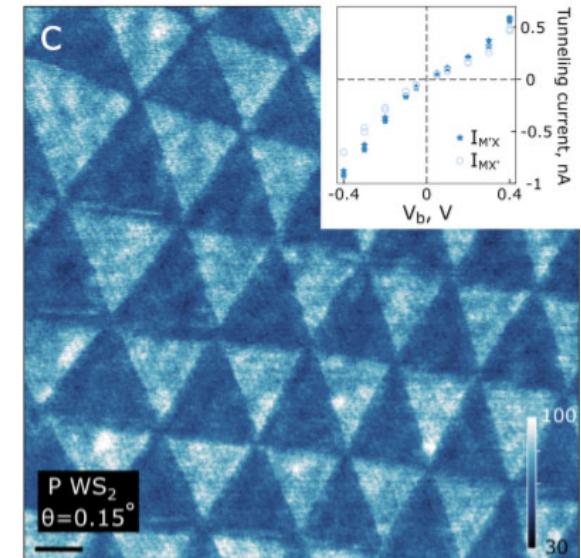
R-type bilayers lack both
mirror reflection and
inversion symmetries



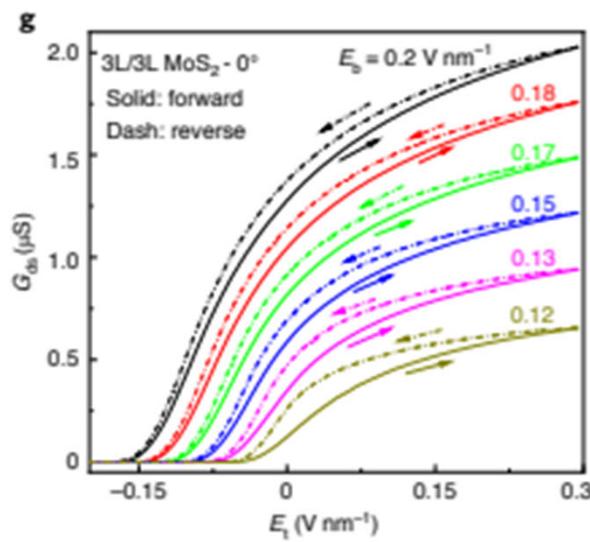
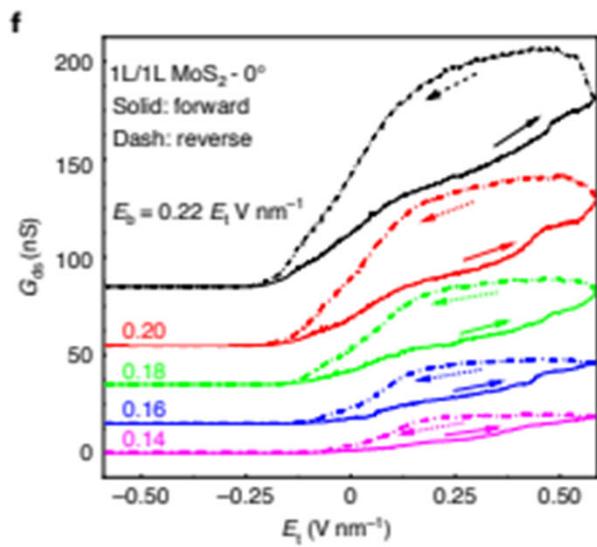
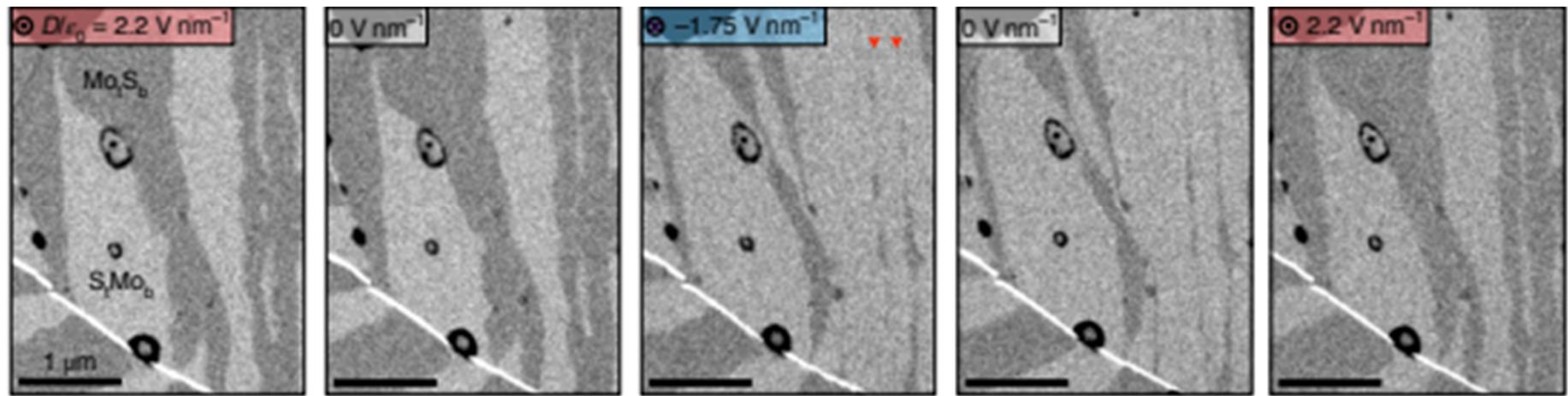
conductive AFM scanning reveals different tunnelling $I(V)$ characteristics for twinned ‘R’-type domains (MX' and XM')

Nature Nanotechnology 15, 592 (2020)

weight of electrons' wavefunctions in the bands (Q-valley) differ for the top and bottom layers



Switching of largest domains: route towards a memristor functionality?



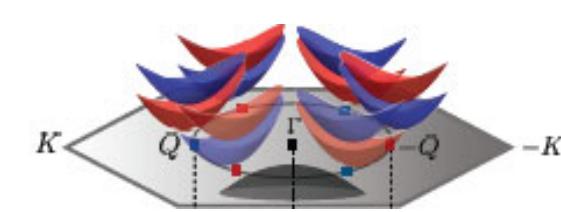
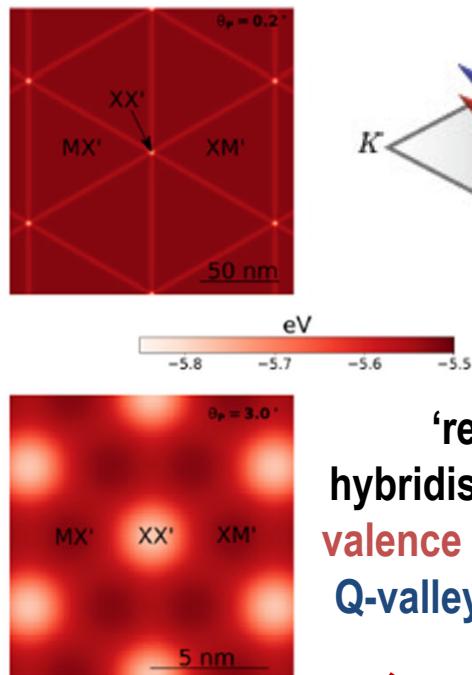
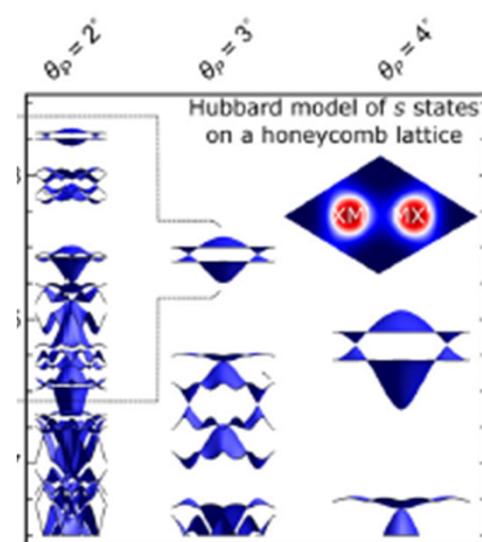
gate-controlled P-bilayer
MoS₂ transistor:
 $G(V_g)$ reflects the
FE polarisation
of large domain areas

Twistronics of transition metal dichalcogenides

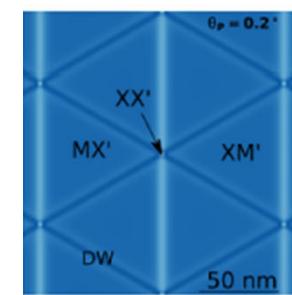
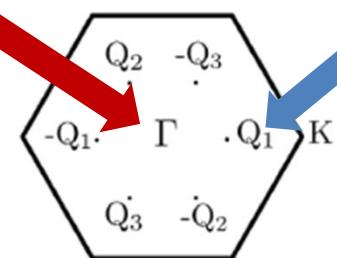
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- Bilayer with inversion symmetry (AP) and without it (P)
- Ferroelectric interfaces and layer-asymmetric band edges in TMDs
- Switching FE polarisation by sliding and ‘string theory’ for domain wall networks
- Band-edge profiles, arrays of QDs, and ‘narrow moiré minibands’
- Ferroelectric few-layer graphene

QDs and moiré superlattice minibands in small-angle twisted P-homobilayers of MoS₂, MoSe₂, WS₂

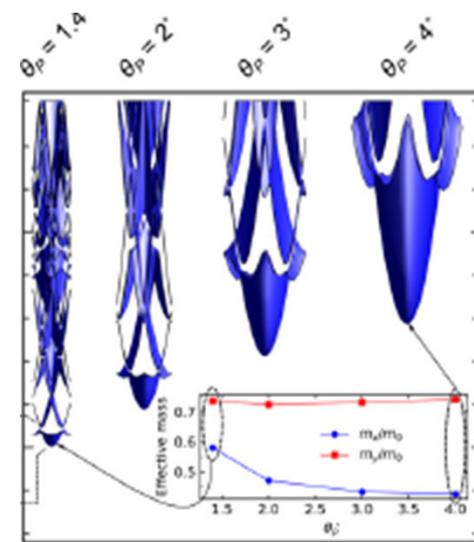
boxes for Γ -valley holes in 2H domains



'resonant' interlayer hybridisation promotes Γ -valley valence band edge for holes and Q-valley conduction band edge for electrons

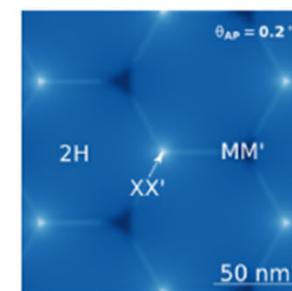
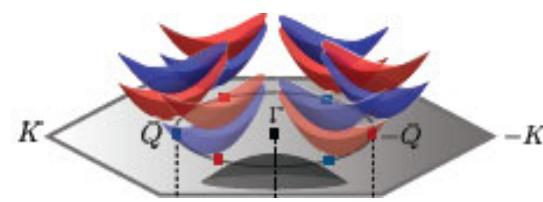
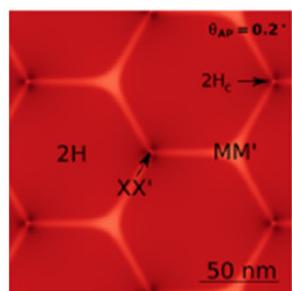
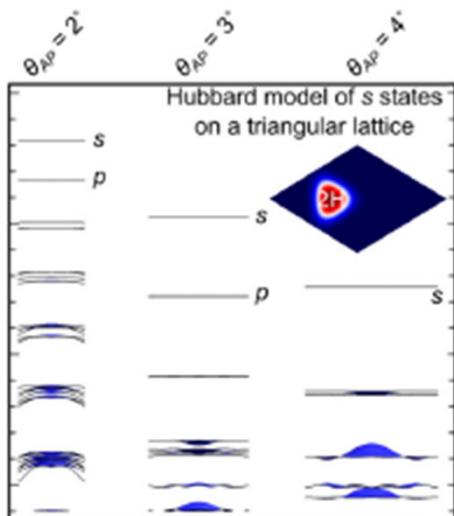


Networks of quantum wires for Q-valley electrons

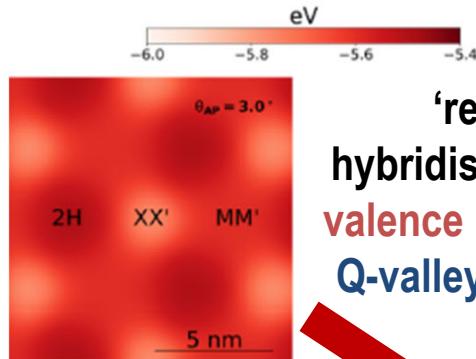


QDs and moiré superlattice minibands in small-angle twisted AP-homobilayers of MoS₂, MoSe₂, WS₂ – for Γ -valley holes and Q-valley electrons

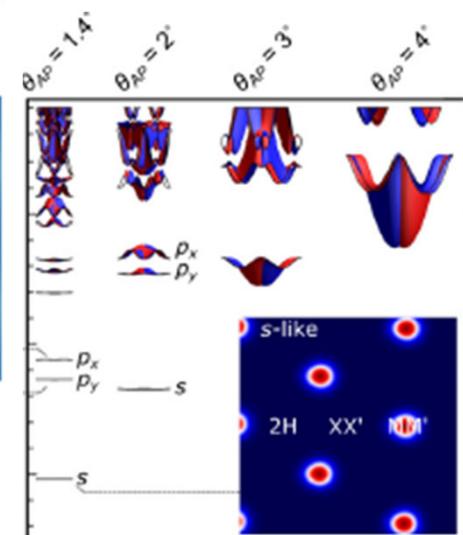
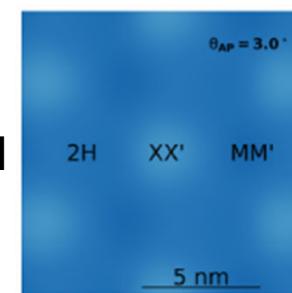
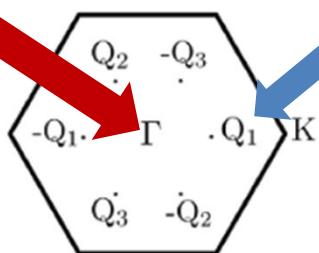
boxes for Γ -valley holes in 2H domains



QDs for Q-valley electrons in MM' corners



'resonant' interlayer hybridisation promotes Γ -valley valence band edge for holes and Q-valley conduction band edge for electrons



Twistronics of transition metal dichalcogenides

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